# 10/770045

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Int No. 7,084,455

Date 9 14 07

Signature:

Joanne Ryan

#### IN THE UNITED STATES PATENT & TRADEMARK OFFICE

APPLICANT(S): Richard A. Blanchard

PATENT NO.: 7,084,455 B2

ISSUED: August 1, 2006

TITLE: POWER SEMICONDUCTOR DEVICE HAVING A VOLTAGE SUSTAINING

REGION THAT INCLUDES TERRACED TRENCH WITH CONTINUOUS

DOPED COLUMNS FORMED IN AN EPITAXIAL LAYER

DOCKET: GS 159 D1

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450 Certificate of Correction

## REQUEST FOR CERTIFICATE OF CORRECTION

Applicant's attorney, on behalf of the Assignee of record, hereby requests the issuance of a Certificate of Correction for the following Applicant errors pursuant to 35 USC §255 and for the following Patent Office errors pursuant to 35 USC §254:

### Correction is requested for the following Patent Office errors:

Col. 3, line 12, begin new paragraph and add

--Accordingly, it would be desirable to provide a method of fabricating the MOSFET structure shown in FIG. 3 that requires a minimum number of epitaxial deposition steps so that it can be produced less expensively while also allowing sufficient control of process parameters so that a high degree of charge compensation can be achieved in adjacent columns of opposite doping type in the drift region of the device.--

Col. 5, line 17, after "trench", change "5201" to --5201--.

Col. 5, line 25, after "layer", change "524," to --5241--.

### Correction is requested for the following Applicant errors:

Abstract, line 18, after "the", change "another" to --other--.

Col. 3, line 33, after "the", change "another" to --other--.

Col. 5, line 9, after "layer", change "502" to --501--.

Col. 6, line 31, after "encompasses", delete --a--.

Col. 6, line 39, after first word "The", change "polysilcon" to --polysilicon--.

The PTO is hereby authorized to charge the undersigned attorney's PTO deposit account #50-1047 accordingly.

A PTO-1050 is enclosed; a Certificate of Correction is respectfully requested.

Respectfully submitted:

Stuart H. Mayer Reg. No. 35,277

Mayer & Williams PC

251 North Avenue West, 2<sup>nd</sup> Floor

Westfield, NJ 07090

Date: 9 - 14 . 6 )

Tel.: 908-518-7700 Fax: 908-518-7795

# UNITED STATES PATENT AND TRADEMARK OFFICE CERTIFICATE OF CORRECTION

PATENT NO: 7,084,455 B2

DATED : August 1, 2006

INVENTOR(S): Richard A. Blanchard

It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

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#### MAILING ADDRESS OF SENDER:

Stuart H. Mayer Reg. No. 35,277 Mayer & Williams PC 251 North Avenue West, 2<sup>nd</sup> Floor Westfield, NJ 07090 PATENT NO.

No. of additional copies \_\_\_\_\_1\_\_\_

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(Also Form PTO-1050)

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